NAKAMURA et al. Serial No. 09/809,038

IN THE CLAIMS

Cancel claims 65 and 67-70.

Please substitute the following amended claim for a corresponding claim previously presented. A copy of the amended claim showing current revisions is attached.

71. (Amended) A nitride semiconductor light-emitting device comprising:

a first n-type clad layer comprising an n-type nitride semiconductor containing indium and gallium;

a first p-type clad layer comprising a p-type nitride semiconductor containing indium and gallium;

an active layer provided between said first n-type and p-type clad layers and having a multi-quantum well structure including a well layer comprising a nitride semiconductor represented by $In_xGa_{1-x}N$, where 0 < x < 1, and a barrier layer comprising a nitride semiconductor represented by $In_yGa_{1-y}N$, where $0 \le y < 1$;

a second n-type clad layer comprising an n-type nitride semiconductor containing aluminum and gallium, said second n-type clad layer having a larger band gap than said first n-type clad layer, said second n-type clad layer being provided over said first n-type clad layer; and

a second p-type clad layer comprising a p-type nitride semiconductor containing aluminum and gallium, said second p-type clad layer having a larger band gap than said first p-type clad layer, and said second p-type clad layer being provided over said first p-type clad layer.